

IN THE CLAIMS:

Please amend the claims as follows:

Claim 1 (Currently Amended): An in-plane switching mode liquid crystal display device comprising:

first and second substrates having an array region and a sealant region along a periphery of the array region;

a sealant in the sealant region attaching the first and second substrates;

a metallic black matrix formed in the sealant region that extends into ~~and in~~ the array region of the first substrate;

a color filter on the metallic black matrix extending into the array region from the sealant region;

an organic layer on the color filter; and

a liquid crystal layer between the first and second substrates.

Claim 2 (Original): The device of claim 1, wherein the metallic black matrix is one of Cr and CrO_x.

Claim 3 (Original): The device of claim 1, wherein the organic layer is formed in the array region.

Claim 4 (Original): The device of claim 3, wherein the organic layer is in direct contact with the metallic black matrix.

Claim 5 (Original): The device of claim 1, wherein the organic layer is formed in the array region and in the sealant region.

Claim 6 (Original): The device of claim 5, wherein the organic layer is in direct contact with the sealant.

Claim 7 (Original): The device of claim 1, wherein the second substrate comprises:
gate lines and data lines arranged vertically and horizontally to define a pixel region;
a thin film transistor adjacent each crossing of the gate and data lines;
a gate pad and a data pad at an end of the gate and data lines; and
a common electrode and a pixel electrode in the pixel region.

Claim 8 (Currently Amended): A method for fabricating an in-plane switching mode liquid crystal display device, comprising:
providing first and second substrates having a sealant region and an array region;
forming a metallic black matrix in the sealant region that extends into ~~and in~~ the array region of the first substrate;
forming a color filter on the metallic black matrix extending into the array region from the sealant region;
forming an organic layer on the color filter;

forming a sealant in the sealant region; and
attaching the first and second substrates by the sealant.

Claim 9 (Original): The method of claim 8, wherein the metallic black matrix is one of Cr and CrO_x .

Claim 10 (Original): The method of claim 8, wherein the organic layer is formed in the array region.

Claim 11 (Original): The method of claim 8, wherein the organic layer is formed in the sealant region and the array region.

Claim 12 (Original): The method of claim 8, further comprising:
forming a thin film transistor, a pixel electrode and a common electrode on the second substrate.

Claim 13 (Original): The method of claim 8, further comprising:
forming a liquid crystal layer between the first and second substrates.

Claim 14 (New): The device of claim 1, wherein the black matrix extends over at least one thin film transistor in the array region.

Claim 15 (New): The device of claim 8, wherein the black matrix extends over at least one thin film transistor in the array region.